



Sustainable nanomaterials for energy conversion and environmental remediation

Edited by Pablo Jiménez Calvo, Ujjal K. Gautam and Lucia
Helena Mascaro

Imprint

Beilstein Journal of Nanotechnology
www.bjnano.org
ISSN 2190-4286
Email: journals-support@beilstein-institut.de

The *Beilstein Journal of Nanotechnology* is published by the Beilstein-Institut zur Förderung der Chemischen Wissenschaften.

Beilstein-Institut zur Förderung der
Chemischen Wissenschaften
Trakehner Straße 7–9
60487 Frankfurt am Main
Germany
www.beilstein-institut.de

The copyright to this document as a whole, which is published in the *Beilstein Journal of Nanotechnology*, is held by the Beilstein-Institut zur Förderung der Chemischen Wissenschaften. The copyright to the individual articles in this document is held by the respective authors, subject to a Creative Commons Attribution license.



Glycerol photoelectrochemical oxidation reaction at carbon nitrides/BiVO₄ materials

Charles Garcia da Cunha, Isabelle M. D. Gonzaga, Cristian Hessel, Izadora F. Reis, Ivo F. Teixeira, Lucia H. Mascaro and Elton Sitta*

Full Research Paper

Open Access

Address:
Federal University of São Carlos, São Carlos, SP, Brazil

Beilstein J. Nanotechnol. **2026**, *17*, 806–817.
<https://doi.org/10.3762/bjnano.17.57>

Email:
Elton Sitta* - esitta@ufscar.br

Received: 10 December 2025
Accepted: 21 May 2026
Published: 17 June 2026

* Corresponding author

Keywords:
biomass valorization; bismuth vanadate; glycerol valorization;
heterojunctions; photoelectrochemistry

This article is part of the thematic issue "Sustainable nanomaterials for energy conversion and environmental remediation".

Associate Editor: C. T. Yavuz



© 2026 da Cunha et al.; licensee Beilstein-Institut.
License and terms: see end of document.

Abstract

The H₂ evolution from water electrolysis can be coupled with co-generation of other added-value products through biomass oxidation. In this study, we investigate the photoelectrochemical oxidation of glycerol using visible-light-responsive carbon nitride / bismuth vanadate (CN/BiVO₄) heterojunction photoelectrocatalysts. Different CN materials were explored, including polymeric carbon nitride (PCN), crystalline poly(heptazine imides) (PHI-Cat, in which Cat = Na, K, or Cs), and poly(triazine imide) (PTI-Li). The CN materials were spin-coated onto fluorine-doped tin oxide (FTO) substrates, followed by the Bi electrodeposition step and conversion to BiVO₄ in the presence of vanadyl acetylacetonate at 500 °C for 2 h. The CN/BiVO₄ heterojunctions presented bandgap energy values, E_g , similar to pure BiVO₄. X-ray diffraction analysis also revealed that the BiVO₄ phase was not altered by the presence of the CN. However, scanning electron microscopy analysis coupled to energy-dispersive X-ray spectroscopy (SEM-EDS) revealed regions rich in Bi and V, and others rich in C and N, suggesting the formation of heterojunctions. Photoelectrochemical studies demonstrated that BiVO₄ is active for both water and glycerol (1.0 mol·L⁻¹) oxidation, with a fourfold increase in photocurrent at 1.23 V vs reversible hydrogen electrode (RHE) upon glycerol addition. Clearly, the type of nitride employed in the heterojunctions influences the activity of the material for glycerol oxidation, with the photocurrent at 1.23 V vs RHE following the order: PCN/BiVO₄ > BiVO₄ ≈ PHI-Cs/BiVO₄ > PHI-K/BiVO₄ ≈ PHI-Na/BiVO₄ > PTI(Li)/BiVO₄. The SEM-EDS analysis after electrochemical tests revealed that the presence of crystalline CNs induces the segregation of vanadium oxides, contributing to a decrease in activity. On the other hand, the superior performance of PCN/BiVO₄ is attributed to a greater thermal stability of PCN during BiVO₄ synthesis, as indicated by thermogravimetric analysis. These findings highlight the dual importance of electronic compatibility and thermal resilience of CN materials in designing efficient heterojunction photoanodes for biomass-assisted hydrogen production.

Introduction

Hydrogen production based on sustainable and renewable energy sources (the so-called green-H₂) is a promising alternative for energy storage, with potential applications in fuel cells and the chemical industry [1]. Among the various methods of producing green-H₂ [2], water photoelectrolysis [3] allows the direct use of solar energy, decreasing reliance on fossil fuels, and having potential for large-scale hydrogen production [4]. On the other hand, the challenges related to the sluggish kinetics of the water oxidation reaction, as well as the material stability at the anodes, must be overcome for this technology to be successfully transferred to end users [5].

To address these issues, several efforts have been made to develop efficient catalysts to improve the kinetics of the water oxidation reaction [6]. These strategies include the synthesis of new photocatalysts, such as metal oxides, doped oxides, heterojunctions, and protective layers to enhance charge transfer at both interfaces and in the bulk, thereby lowering the activation energy barriers [7]. In this sense, bismuth vanadate (BiVO₄) has been pointed out as a promising material, as it presents high chemical stability and a wide absorption range of solar radiation [8-10]. To overcome the limitations associated with the low electrical conductivity of BiVO₄, sluggish surface kinetics and the recombination of electron-hole pairs [11], it is possible to combine BiVO₄ with other materials, such as carbon nitrides materials [12].

Carbon nitrides (CNs) can be classified into two main groups: polymeric carbon nitride (PCN) and crystalline carbon nitrides – poly(heptazine imide) (PHI) and poly(triazine imide) (PTI). While both share a fundamental heptazine or triazine-based backbone, they significantly differ in structure, crystallinity, and properties. PCN is the commonly synthesized form of CN due to its simple preparation methods. However, it suffers from low crystallinity, structural disorder, and poor reproducibility, which limit its performance in various applications [13,14]. In contrast, crystalline carbon nitrides, namely PHI and PTI, exhibit superior molecular organization, greater stability, and enhanced functional properties. PHI is composed of heptazine units linked through nitrogen bridges, resulting in a pseudo-hexagonal 2D lattice. Meanwhile, PTI consists of triazine units, forming a rigid and highly stable framework. This structural arrangement significantly improves charge mobility and light absorption, both of which are critical for catalytic activity [15]. Additionally, PHI and PTI possess an intrinsic ionic nature, unlike the neutral PCN, which enhances their interactions with various substrates and expands their potential applications. A key factor in achieving superior crystallinity of PHI and PTI is ionothermal synthesis, where the use of salts facilitates a well-ordered molecular arrangement and minimizes structural defects

[16]. CN materials have been extensively studied as environmentally friendly semiconductors with remarkable photocatalytic properties and facile synthesis [17-21]. Furthermore, it has been demonstrated that incorporating cations during CN synthesis can lead to different structural modifications, varying degrees of crystallinity, and consequently, distinct photocatalytic performance [17-21].

Another strategy to bypass the sluggish kinetics of water oxidation involves employing different processes to deliver the electrons necessary for H₂ production. In this context, the oxidation of small organic molecules has great potential to replace water oxidation in photoelectrochemical cells [22], as these molecules have a considerably lower standard potential, with the possibility to yield value-added products. Indeed, biomass derivatives, such as ethanol and glycerol, are targeted to become a new route for converting solar energy into fuels [23] at both sides of the cells (i.e., while H₂ is produced at the cathode, carboxylic acids, aldehydes, and ketones can be produced at the anode [24]). It is expected that glycerol photoelectrochemical oxidation at BiVO₄ occurs by the following pathway: (i) Photon absorption by BiVO₄, (ii) electron-hole (*e*⁻-*h*⁺) separation, (iii) electron(s) transfer from glycerol molecule to *h*⁺, and (iv) glycerol deprotonation yielding oxidized products as shown in Equation 1. The products usually described in the literature for this process are 1,3-dihydroxyacetone, glyceraldehyde, formic acid, and glyceric acid [25,26].



Hessel et al. compared the photochemical oxidation of methanol, ethylene glycol, and glycerol in CdS [27], BiVO₄ [25], and BiVO₄:Zr,Mo/Pt [25] thin films, concluding that regardless of the material, glycerol oxidation depicted higher photocurrents and provided a protective effect against photocorrosion. The photoelectrochemical activity and selectivity of glycerol oxidation on BiVO₄ are influenced by several factors, including pH [26], electrolyte cation and anion [28], BiVO₄ surface crystallography orientation [29], and bismuth-rich domain within the film [30].

Herein, in order to understand the effect of distinct types of CN materials on CN/BiVO₄ heterojunctions, polymeric (PCN), poly(heptazine imide) (PHI) and poly(triazine imide) (PTI) carbon nitrides were synthesized and employed to fabricate CN/BiVO₄ electrodes. These heterojunctions were applied to photoelectrochemical glycerol oxidation. Furthermore, the effect of Na, K, and Cs alkaline cations in the PHI structures

was investigated and the photoactivity for glycerol oxidation was discussed in terms of CN thermal stability.

Materials and Methods

Synthesis of carbon nitrides

The PCN synthesis followed the procedure described by Silva et al. [31]. Briefly, the synthesis was carried out in a hydrothermal reactor for the polymerization of melamine in 25 mL of distilled water at 80 °C for 4 h. At the end of the process, the solvent was evaporated, and the resulting solid underwent thermal treatment at 550 °C for 30 min. The procedure described by Chen et al. [15] was adopted for PHI and PTI synthesis, in which melamine (1 g) was mixed with 10 g of alkali metal chlorides (Li, Na, K, or Cs), and the mixture was heated in a muffle furnace under a N₂ atmosphere. The heating conditions were adjusted based on the alkali metal chloride used: for Na, the system was heated at 600 °C for 4 h, for Li at 600 °C for 8 h, and for both K and Cs at 550 °C for 4 h. After heating, the product was washed with distilled water and stirred at 95 °C for 3 h. The suspension was then centrifuged at 9000 rpm for 5 min, dried in an oven at 60 °C, and stored for later use. While the synthesis containing LiCl results in the PTI structure, the other salts yield PHI [31,32].

Carbon nitride deposition onto FTO

An amount of 20 mg of each CN was dispersed into 5 mL of poly(ethylene glycol) (PEG-300, Sigma-Aldrich, ACS reagent, 99.99%) for 30 min in an ultrasound bath (Soni-tech ultrasonic cleaner). Subsequently, 60 µL of a freshly sonicated suspension was drop-cast onto a 1 × 1 cm FTO (Sigma-Aldrich, surface resistivity ≈ 7 Ω/sq) substrate cleaned/pre-treated according to the protocol described by Malviya et al. [31,32]. The system was spun at 2000 rpm for 30 s in a spin coater device (WS-650Hz-23NPPB). Finally, the C₃N₄/FTO layer was placed in a drying oven at a temperature of 300 °C for 1 h.

Synthesis of heterojunctions

Initially, bismuth was electrodeposited from a bismuth(III) nitrate (Sigma-Aldrich, ACS reagent, 99.99%) solution (0.02 mol·L⁻¹ in ethylene glycol) by applying a -1.8 V vs Ag/AgCl/KCl_{sat} potential for five cycles (2 s at open circuit between the cycles) until reaching a charge density of -0.04 C·cm⁻² at each cycle (total charge of -0.2 C·cm⁻²) [33]. The electrodeposition was performed on both unmodified and FTO-modified substrates with different CN. Subsequently, 60 µL of a vanadium(III) acetylacetonate (Sigma-Aldrich, ACS reagent, 99.99%) solution (0.2 mol·L⁻¹ in DMSO) was drop-cast onto the freshly electrodeposited Bi layer, and the material was heated at 10 °C·min⁻¹ up to 500 °C and held for 2 h. After completing this step, the films were soaked into NaOH solution (1.0 mol·L⁻¹) for 30 min to remove the excess of unreacted

vanadium, washed with distilled water, and dried at ambient temperature.

Characterization of materials

Prior to deposition on FTO substrates, the different types of CN were structurally and morphologically characterized. Thermogravimetric (TGA) analysis (Netzsch, 209 F3) was performed from 25 to 800 °C at a heating rate of 10 °C·min⁻¹ under a synthetic air atmosphere. X-ray diffraction (XRD) patterns (XRD, Rigaku Ultima IV 6000) were acquired from 10° to 80° at a rate of 2°·min⁻¹ with a step size of 0.02°. Morphological features and elemental composition were determined by field-emission scanning electron microscopy (FEG-SEM; Zeiss Supra35) coupled with energy-dispersive X-ray spectroscopy (EDS), operating at 15 kV. Optical properties were investigated using ultraviolet–visible spectroscopy in the diffuse reflectance mode (Agilent-Cary Series UV–vis–NIR) in the wavelength range from 800 to 300 nm at 600 nm·min⁻¹. The optical energy band gap (E_g) values were estimated using the Kubelka–Munk function applied the Tauc equation (Supporting Information File 1, Equation S1) [34].

The photoelectrochemical characterization was carried out using a potentiostat/galvanostat (PGSTAT302N, Autolab, Metrohm). Measurements were performed in a three-electrode cell containing a Na₂SO₄ solution (0.5 mol·L⁻¹, pH 6.8), BiVO₄ or CN/BiVO₄ as working electrode (WE), a platinum sheet as the counter electrode, and a Ag/AgCl/KCl_{sat} electrode as potential reference. The light source was provided by solar simulator (Oriol, LCS-100, AM-1.5G) with 100 mW·cm⁻² of irradiance illuminating the back side of the WE through a lateral quartz window in the electrochemical cell (Supporting Information File 1, Figure S1). Linear sweep voltammetry (LSV) curves were acquired in the dark and under simulated solar exposure, ranging from -0.6 to 1.4 V vs Ag/AgCl/KCl_{sat} at 50 mV·s⁻¹.

Results and Discussion

Physical characterization

The CNs thermostability was evaluated by TGA, as shown in Figure 1. PCN presented greater thermal stability at temperatures below 500 °C, the mass losses being more pronounced for temperatures higher than 550 °C, resulting in a residual mass of 3.3% at 700 °C. On the other hand, remaining materials (PTI-Li, PHI-Na, and PHI-K) exhibited mass losses at lower temperatures, which can be divided into two stages: (i) mass losses at $T < 300$ °C are probably due to water in the CN structures, which is connected to the residual water after the last part of the synthesis protocol which involves dissolution in water; (ii) mass losses at $T > 300$ °C are likely connected with the CN degradation, which happens at considerably lower temperatures than those observed for PCN. Interestingly, even at $T = 800$ °C in an

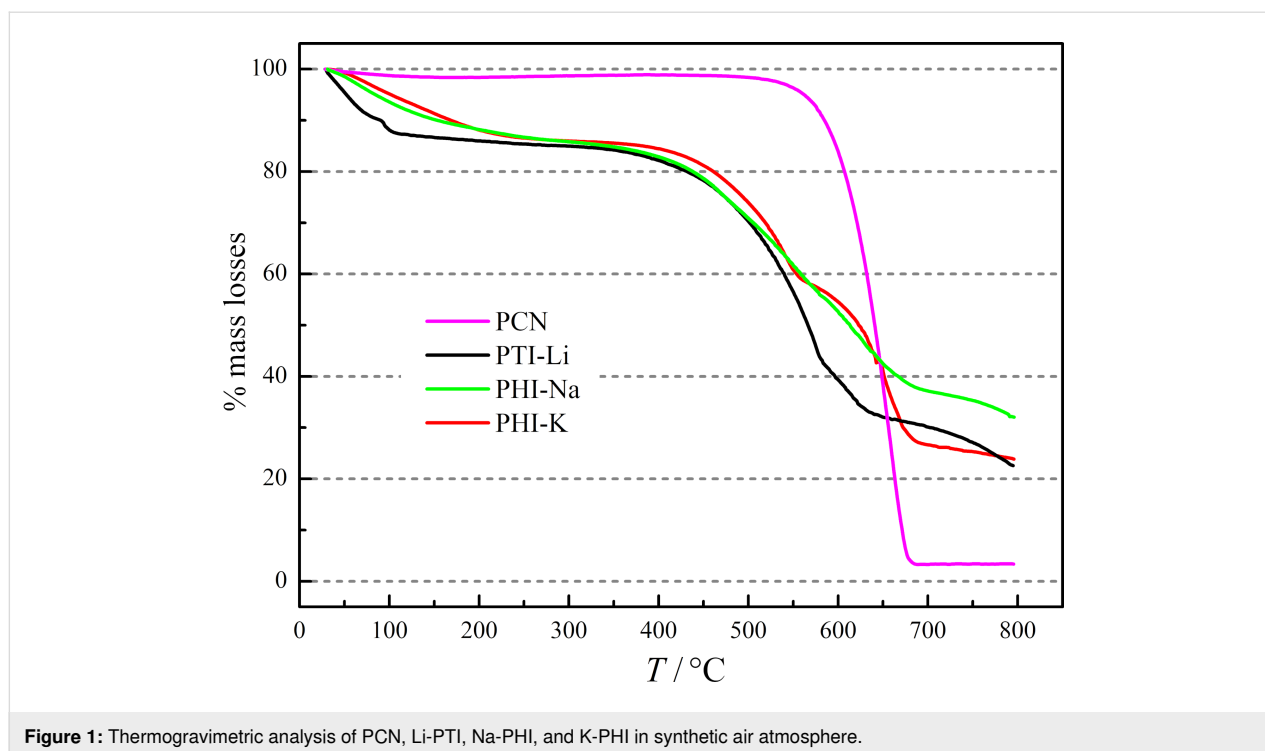


Figure 1: Thermogravimetric analysis of PCN, Li-PTI, Na-PHI, and K-PHI in synthetic air atmosphere.

oxidizing atmosphere, the materials still maintain 20–35% of their initial mass.

To shed some light on CN structure degradation and the residual nature of the materials at high temperature, a thermal treatment was performed at 500 °C for 2 h and the X-ray diffractograms were collected for the materials with the highest (PCN) and the lowest (PTI-Li) thermal stability. Supporting Information File 1, Figure S2 shows that PCN maintains the XRD pattern after the thermal treatment. On the other hand, PTI-Li suffers structural transformations during thermal treatment, resulting in a strong inhibition of the peaks at 11.8°, 21.2°, and 27.0° and the appearance of an intense and sharp peak at 31.8°. Supporting Information File 1, Figure S3 compares the PTI-Li XRD pattern with simulated XRD patterns of several lithium (hydro)oxides but it is not possible to address the observed features for only one species. Therefore, the material obtained after the thermal treatment seems to be a mixture of unreacted PCN with possibly lithium (hydro)oxides.

Figure 2 shows the XRD for the synthesized CNs/BiVO₄ films and for BiVO₄ and PCN films onto FTO substrate. The XRD pattern for clean FTO was also included (gray line) making it easier to observe its contribution to the other diffractograms. Notably, in all films, it is possible to observe the diffraction peaks related to the FTO (since the incident beam interacts with all layers of the material). The main FTO contributions are highlighted by the gray dashed lines. The film containing only

BiVO₄ presents a diffraction pattern consistent with the monoclinic structure, according to ICDD file 00-044-0081. The following planes stand out, attested by the peaks that appear at $2\theta = 18.7^\circ$ (011), 28.7° (-121), 30.5° (004), 34.5° (200), 35.2° (202), 39.7° (211), 42.4° (105), and 47.1° (024) in agreement with the assignments reported by Cheng et al. [35]. These contributions are indicated by the red dashed lines. Furthermore, in films containing C₃N₄, it is not possible to observe its crystalline phase, likely due to the thin layer of this material on FTO. Supporting Information File 1, Figure S2 brings the CNs XRD for pristine powder forms in which the most intense peaks occur in the range from 26.8 to 28° for PTI-Li, PHI-Na, and PCN. Specifically, for PCN no peaks in this range are observed in Figure 2 for PCN onto FTO. Moreover, BiVO₄ depicts an intense peak in this region, hindering any possible PCN contribution in PCN/BiVO₄ XRD. Therefore, for the CNs/BiVO₄ films, both BiVO₄ and FTO characteristic diffraction peaks are observed, whereas for the PCN film on FTO only the characteristic FTO diffraction peaks are detected.

FEG-SEM images (Figure 3) were performed on the surface (top view) of the BiVO₄ and CN/BiVO₄ films. Globular structures characteristic of bismuth vanadate can be recognized along the surface, these patterns have been reported in the literature for BiVO₄ synthesized by similar procedures [25,33,36]. For the materials containing heterojunctions, the globular structures occurred in a different way for each material, which could be attributed to nucleation during the heat treatment, depending

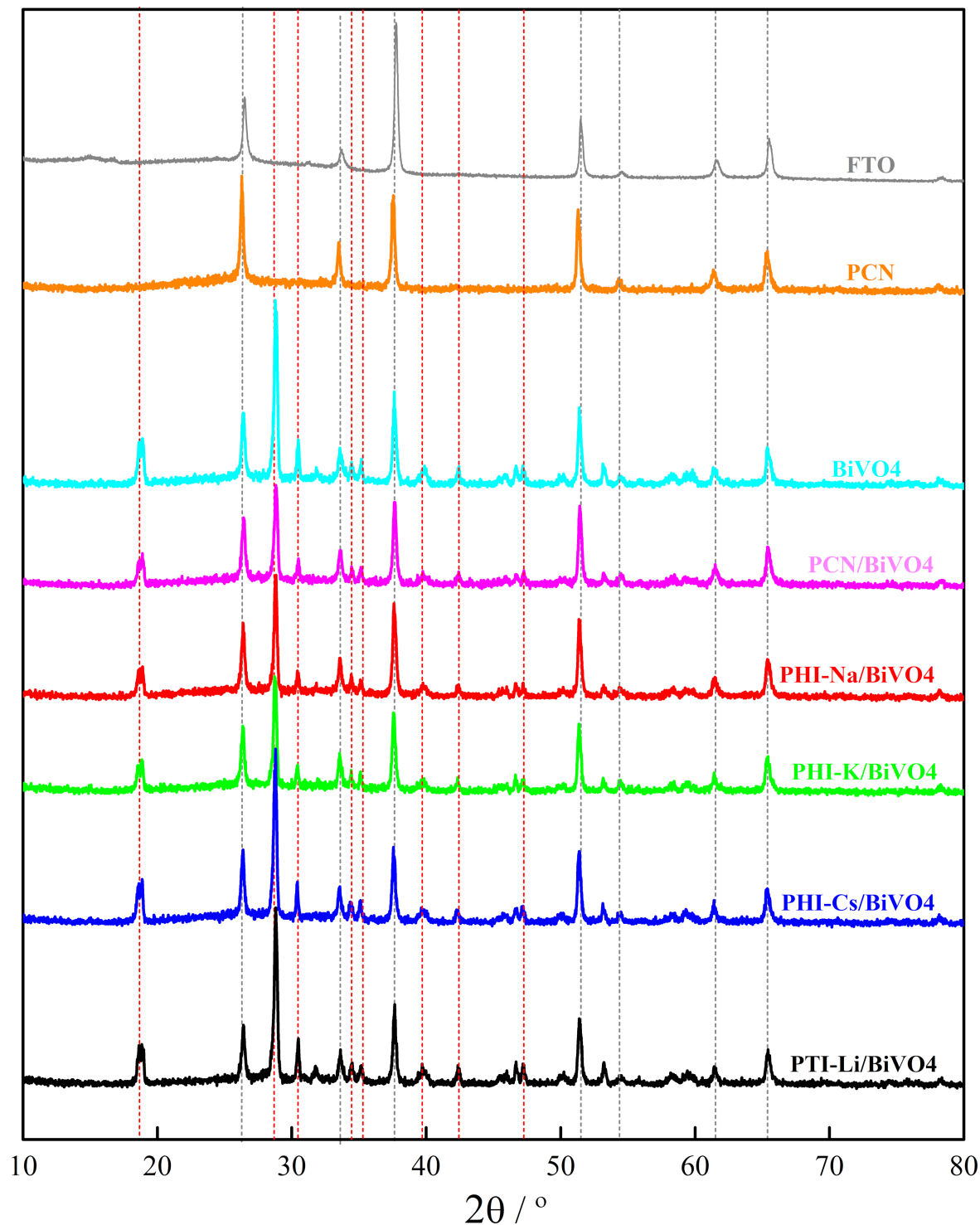


Figure 2: X-ray diffractograms for the material deposited onto FTO substrates.

on the alkali cation present or the CN crystallinity. For instance, in PCN/BiVO₄ and PHI-Na/BiVO₄ (Figure 3b and 3c), the globules decreased in size compared to pure BiVO₄, whereas in

PHI-K/BiVO₄, PHI-Cs/BiVO₄, and PHI-Li/BiVO₄, they tended to agglomerate into elongated morphologies. SEM-EDS images for PHI-Li/BiVO₄ (Supporting Information File 1, Figure S4)

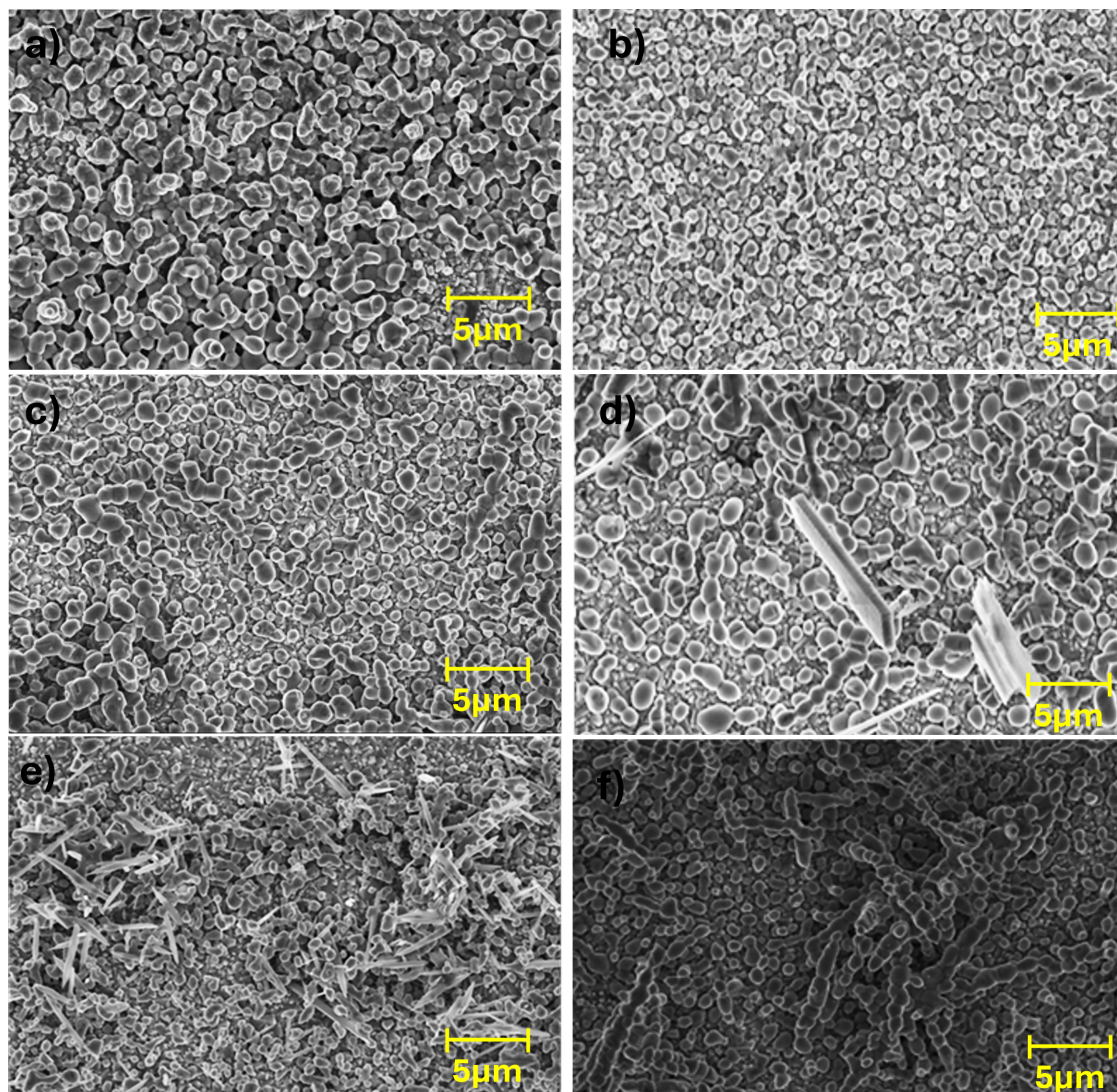


Figure 3: FEG-SEM images for a) BiVO_4 ; b) PCN/BiVO_4 ; c) PHI-Na/BiVO_4 ; d) PTI-Li/BiVO_4 ; e) PHI-K/BiVO_4 ; and f) PHI-Cs/BiVO_4 film onto FTO.

revealed that the elongated structures are richer in both vanadium and oxygen than in bismuth. Therefore, it can be concluded these structures are mainly vanadium oxides.

Cross-sectional FEG-SEM-EDS analysis was performed on PCN/BiVO_4 and PHI-Li/BiVO_4 , (Figure 4) (i.e., the materials that showed the highest and lowest thermal stability, respectively). From the bottom to the top part of both samples, it is possible to recognize the following elements: Si from the glass support, Sn from the FTO layer, both C and N from the CN layer, and both Bi and V from the BiVO_4 layer. The C and N signals appear to be located in the same region as Sn, which can be interpreted as a thin CN layer distributed among the FTO grains. This is in agreement with the PCN/FTO FEG-SEM anal-

ysis (Supporting Information File 1, Figure S5) in which even after the PCN layer deposition, the typical FTO morphology is clearly observed. The Bi and V signals appear above the other elements, confirming that BiVO_4 is the species in contact with the electrolyte and suggesting the formation of a heterojunction. Finally, the scattered-colored dots in the images indicate that the analysis is near the detection limit of the instrument; therefore, the data should be qualitatively interpreted.

Figure 5 shows the Tauc plots derived from the diffuse reflectance spectra collected for the CN/BiVO_4 materials, assuming an indirect allowed transition. The bandgap energy values (E_g) were determined by the linear extrapolation of the linear region of the plots to the baseline. The E_g values were calculated in

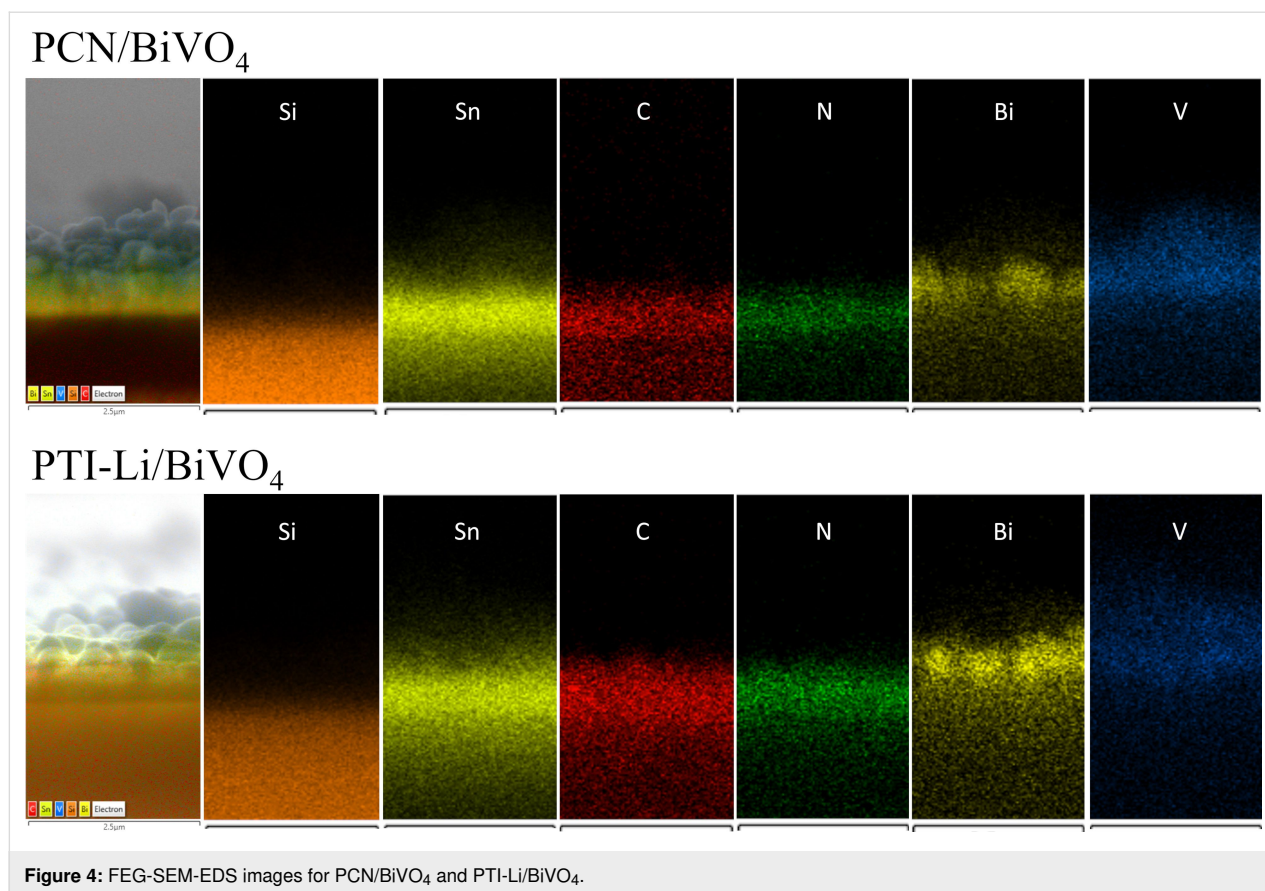


Figure 4: FEG-SEM-EDS images for PCN/BiVO₄ and PTI-Li/BiVO₄.

triplicate for each material, and the mean values, along with their standard deviations, are shown in Figure 5b. Overall, there are no significant variations among the materials, indicating that the underlying CN layer exerts little influence on the E_g of BiVO₄, which agrees with previous reports [37,38]. Furthermore, the E_g values for the CN samples in powder form were also determined. In this case, the E_g values are higher than those for CN/BiVO₄ films, as indicated by the blue triangles in Figure 5b, in agreement with the literature values [31].

Electrochemical characterization

Photoelectrochemical activities were evaluated by LSV at a scan rate of 0.05 V·s⁻¹ in a Na₂SO₄ solution (0.5 mol·L⁻¹, pH 6.8). Initially, the activity of the BiVO₄ film was investigated for water oxidation (in the supporting electrolyte alone) and subsequently for glycerol oxidation after the addition of 1.0 mol·L⁻¹ glycerol (Figure 6a). Notably, in the presence of glycerol and simulated light (glycerol/on), the anodic photocurrent onset potential is negatively shifted by 300 mV and the photocurrent densities at 0.6 and 1.5 V are 4.3 and 1.5 times higher than those for water oxidation (water/on), respectively. The dotted lines also confirm that the material is inactive in the dark, regardless of the species in the electrolyte (water/off and glycerol/off).

Intermittent light measurements (chopped light) were also performed to evaluate the influence of pulsed light on the BiVO₄ photoactivity (Supporting Information File 1, Figures S6 and S7). In the presence of glycerol, the photocurrent closely follows the light on/off transitions, showing stable and sustained values under illumination. In contrast, under water oxidation conditions (i.e., in the absence of glycerol), a sharp current peak appears within fractions of a second upon illumination. These transient current peaks are related to the accumulation of holes (h^+) at the surface of the semiconductor, caused by the sluggish water oxidation kinetics [34].

Following the same protocol employed to test the BiVO₄, the photoelectrochemical activity of the CN/BiVO₄ films toward glycerol photoelectrochemical oxidation was also evaluated, and the results are displayed in Figure 6b. For comparison, the curve for the pristine BiVO₄ film was also included. Interestingly, the onset potential for glycerol oxidation does not depend on the CN type used on the heterojunction, suggesting no doping effect on BiVO₄. On the other hand, at higher applied potentials, the photocurrent density strongly depends on the CN type. The materials PTI-Li, PHI-Na, and PHI-K combined with BiVO₄ tend to decrease the overall activity for glycerol oxidation. In turn, PHI-Cs/BiVO₄ exhibits an activity similar to that

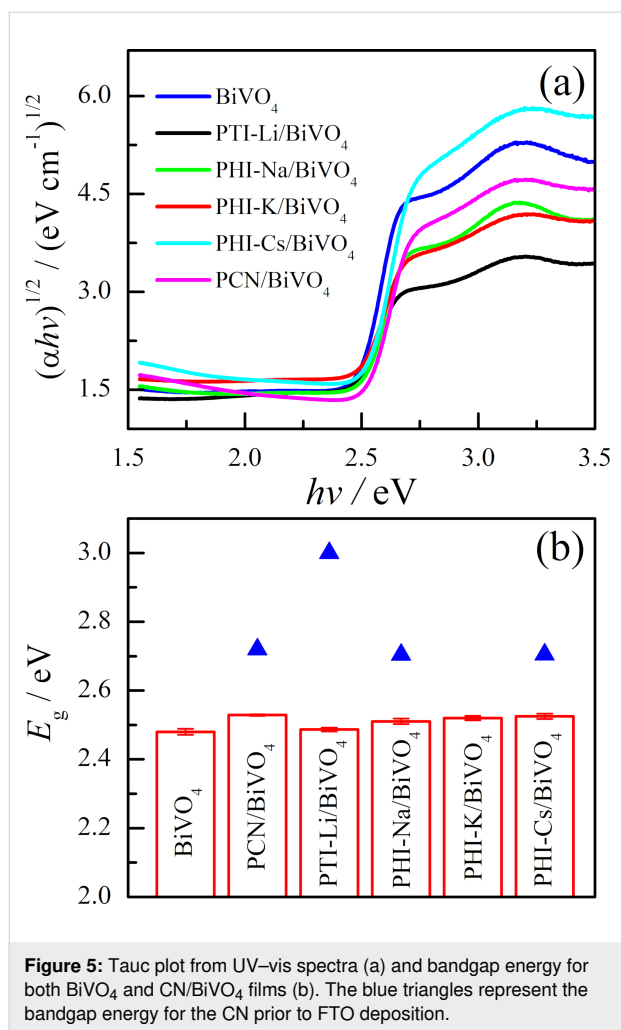


Figure 5: Tauc plot from UV–vis spectra (a) and bandgap energy for both BiVO_4 and CN/BiVO_4 films (b). The blue triangles represent the bandgap energy for the CN prior to FTO deposition.

of bare BiVO_4 , while PCN/BiVO_4 displays a higher activity. These photoelectrochemical tests were performed in triplicate using independently prepared electrodes, and the mean photocurrent densities at 0.6 V are shown in Figure 6b. Photocurrent densities under chopped illumination are also presented in Supporting Information File 1, Figures S8–S12 and follow the same trend observed under continuous irradiance. The PCN activity for glycerol was also tested (Supporting Information File 1, Figure S8b) in the same experimental conditions and released photocurrent of ca. $1 \mu\text{A}\cdot\text{cm}^{-2}$. Therefore, the positive effects observed on composite materials come from the synergy between BiVO_4 and CN.

Long-term electrolysis experiments were performed for PCN/BiVO_4 films at $E = 0.6$ V vs Ag/AgCl/KCl (1.23 V vs RHE) for 20 h under simulated solar illumination (Figure 7a). The photocurrent changes suggest that no corrosion effect or deactivation processes are occurring at the surface during glycerol oxidation. The inserts show FEG-SEM images of the surface before and after electrolysis, confirming that glycerol photo-

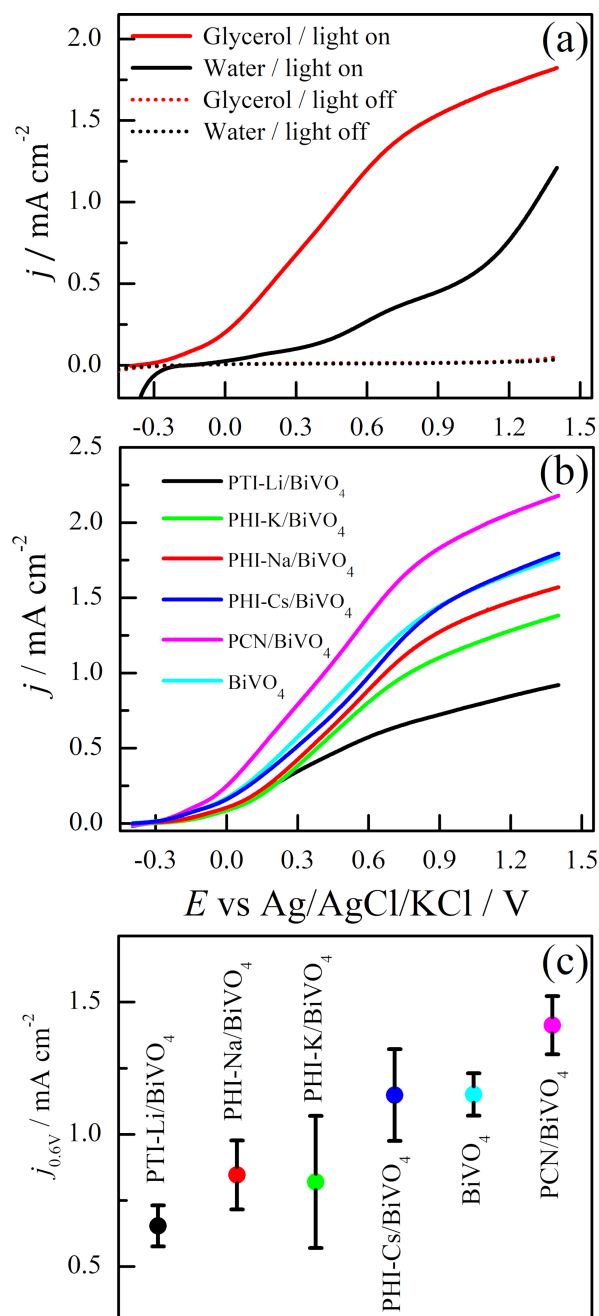
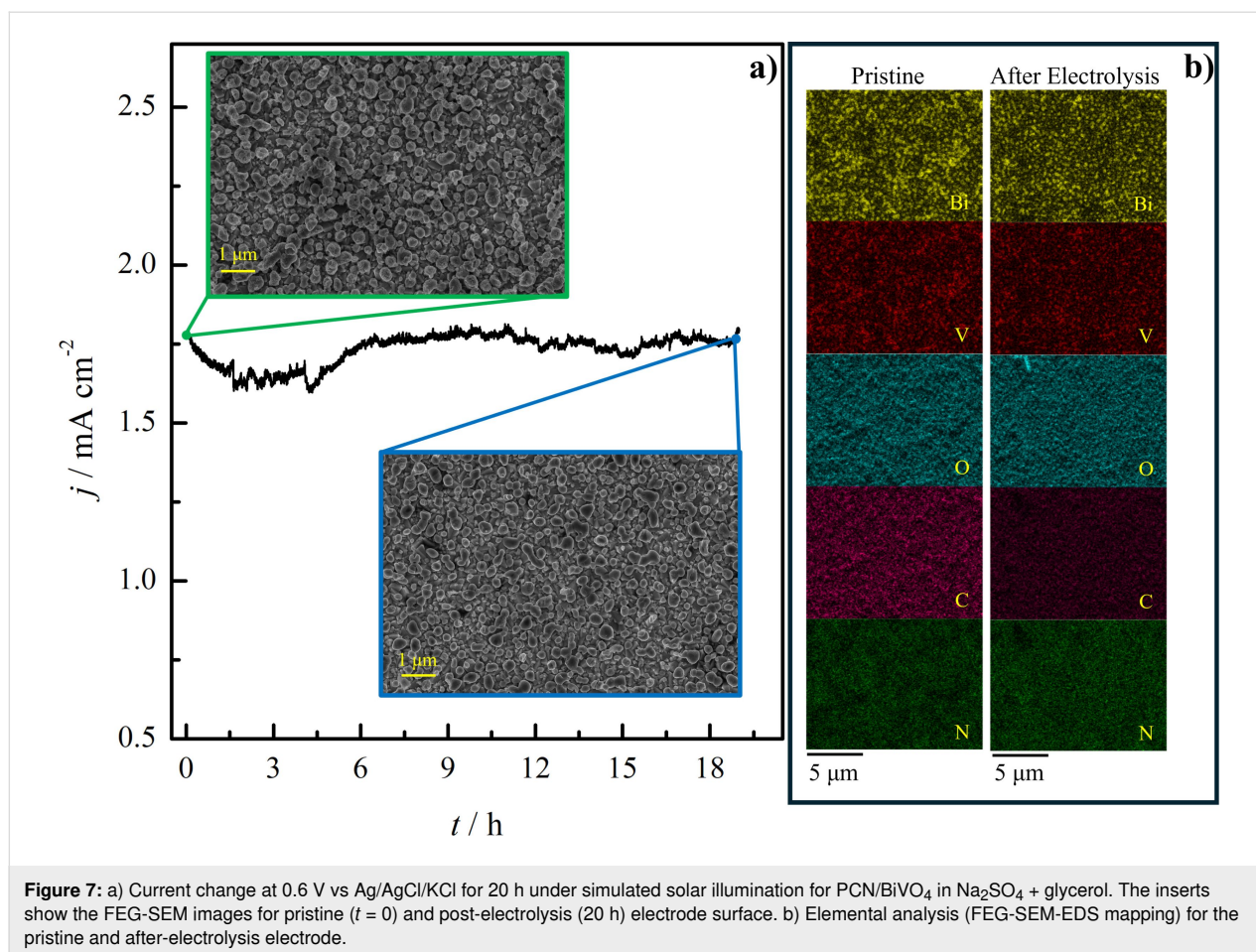


Figure 6: Comparison between photoelectrochemical oxidation of water and glycerol at the BiVO_4 photoanode under simulated solar illumination (light on) and dark (light off). (a) Glycerol photoelectrochemical oxidation at distinct CN-X/BiVO_4 films under simulated solar illumination. (b) Photocurrent mean values obtained in (b) at $E = 0.6$ V. (c) The error bars represent the standard deviations from three distinct independently produced films. Other conditions: electrolyte: Na_2SO_4 ($0.5 \text{ mol}\cdot\text{L}^{-1}$, pH 6.8) + glycerol ($1.0 \text{ mol}\cdot\text{L}^{-1}$) $\nu = 0.05 \text{ V}\cdot\text{s}^{-1}$.

electrochemical oxidation does not modify the surface condition. Finally, the Figure 7b brings the FEG-SEM-EDS elemental mapping before and after electrolysis. Comparing the images, all elements in pristine material are present after elec-



trolysis (i.e., it has not leached during electrolysis). Therefore, one can conclude the PCN/BiVO₄ is an active and stable material for glycerol photoelectrochemical oxidation.

During the BiVO₄ synthesis, an annealing step at 500 °C is necessary to obtain the monoclinic phase. Given the CNs thermal stabilities, significant structural changes are expected, as indicated by TGA analysis. The materials prepared with PTI-Li, PHI-Na, and PHI-K undergo substantial mass loss during this BiVO₄ synthesis step. In contrast, when coupled with BiVO₄, PCN, the most stable material among the CNs studied, exhibited a photocurrent density 22% higher than that of bare BiVO₄ for the glycerol oxidation at 0.6 V vs Ag/AgCl/KCl_{sat} (1.23 V vs RHE).

However, the inherent CNs thermal stability alone cannot explain the behavior of the entire set of tested materials. For instance, the FEG-SEM-EDS indicates the presence of both C and N under the BiVO₄ layer in the PCN/BiVO₄ and PTI-Li/BiVO₄ films. Therefore, a protective effect exerted by the Bi/BiVO₄ layer over the CNs could be enhancing the thermal stability of the underlying CNs during the BiVO₄ synthesis,

thereby preventing mass loss. Indeed, thermal treatment of the bare CN films deposited onto FTO at 500 °C without the Bi overlayer leads to the complete thermal degradation of the CN layer. Furthermore, we also confirmed that the PTI-Li powder retains its original bandgap energy ($E_g = 3.0$ eV) after the thermal treatment at 500 °C for 2 h (Supporting Information File 1, Figure S13).

The films composed of PHI-K/BiVO₄ and PHI-Cs/BiVO₄ exhibit activities similar to pristine BiVO₄, but the thermal stability of PHI-K/BiVO₄ is comparable to that of PTI-Li. The literature suggests that the crystallinity of PHI structures increases as the cation radius decreases. This means that PHI synthesized in the presence of smaller cations, such as Na⁺, exhibits a higher degree of crystallinity compared to those prepared with larger cations, such as K⁺. This trend can be attributed to the stronger electrostatic interactions and more efficient packing of smaller cations within the negatively charged imide-linked framework. Smaller cations fit more compactly within the pores and interlayer spaces, promoting a more ordered and rigid structural arrangement. In contrast, larger cations, such as K⁺, create greater spatial distortions, leading to reduced crystallinity and a

less well-defined long-range order [15,16,39]. Although it was not possible to confirm these CN structural features by XRD analysis, the photoactivity toward glycerol oxidation follows this trend. In this scenario, the dependence of photoactivity with the CN type could arise from the charge transfer dynamics within the CN layer or at the interface between CN and BiVO₄, both of which can be tuned by the CN crystalline structure.

Considering that the E_g values observed for pristine CNs are maintained after thermal treatment under the Bi layer, the low photoactivity for glycerol oxidation at the PTI-Li/BiVO₄ film could be explained by the high E_g of PTI-Li, which likely hinders proper band alignment with BiVO₄. Both PHI-Na and PHI-Cs exhibited similar E_g values to that of PCN; however, the higher photoactivity of PCN/BiVO₄ likely arises from its superior thermal stability or more favorable band position. Furthermore, it is possible that the CNs thermally treated under Bi/BiVO₄ layer exhibit distinct features from those observed for the pristine materials. Unfortunately, techniques such as XRD and Mott–Schottky measurements, typically employed to estimate the crystalline phase and flat band potential, respectively, are challenging to perform on these CN layers with the features of those thermally treated under the Bi layer.

Interestingly, the higher activity observed for glycerol oxidation in PCN/BiVO₄ is consistent with Gonzaga et al. [12], who reported enhanced BiVO₄ activity when combined with PCN for textile wastewater detoxification. Thus, coupling BiVO₄ with PCN appears to be an effective strategy to boost the photocurrent in BiVO₄-based systems for the oxidation of organic molecules.

Conclusion

CN/BiVO₄ heterojunctions were successfully synthesized and characterized using UV–vis spectroscopy, SEM-EDS, XRD, and TGA. These materials were applied to the photoelectrochemical oxidation of glycerol, with particular attention given to the impact of thermal stability. Compared to bare BiVO₄, heterojunctions based on PTI-Li, PHI-Na, and PHI-K exhibited reduced photoactivity for glycerol oxidation, while PHI-Cs/BiVO₄ showed comparable performance. Notably, the PCN/BiVO₄ heterojunction demonstrated enhanced photoelectrochemical activity relative to that of BiVO₄ alone.

These results highlight the critical role of the CN component in determining the overall performance of the heterojunction. Beyond intrinsic electronic properties, factors such as the nature of the alkali cations, synthesis method, and post-synthesis thermal treatments significantly influence the structural integrity and interfacial behavior of CN materials. Therefore, the design of efficient CN-based heterojunctions must consider not only

the initial properties of the CN but also how these properties evolve under processing conditions relevant to device fabrication and operation.

Supporting Information

Supporting Information File 1

Additional figures.

[<https://www.beilstein-journals.org/bjnano/content/supplementary/2190-4286-17-57-S1.pdf>]

Acknowledgements

The authors thank Shell for the strategic importance of the support given by ANP (Brazil's National Oil, Natural Gas, and Biofuels Agency) through the R&D levy regulation.

Funding

This research was funded by Fundação de Amparo a Pesquisa do Estado de São Paulo, FAPESP, grant numbers #2017/11986-5, #2024/06318-7, #2020/14741-6, #2021/11162-8, #2024/00839-5, #2024/20757-3 and #2021/12394-0, the Conselho Nacional de Desenvolvimento Científico e Tecnológico, CNPq, grant numbers #403064/2021, #310550/2022-0, and #405752/2022, Financiadora de Estudos e Projetos (FINEP) grant numbers #01.22.0179.00, 01.23.0645.00, and 01.23.0662.00.

Author Contributions

Charles Garcia da Cunha: conceptualization; data curation; formal analysis; investigation; methodology; writing – original draft. Isabelle M. D. Gonzaga: conceptualization; data curation; formal analysis; investigation; methodology; writing – original draft. Cristian Hessel: formal analysis; investigation; methodology; writing – original draft. Izadora F. Reis: formal analysis; investigation; methodology; writing – original draft. Ivo F. Teixeira: conceptualization; writing – original draft; writing – review & editing. Lucia H. Mascaro: conceptualization; writing – original draft; writing – review & editing. Elton Sitta: conceptualization; formal analysis; funding acquisition; methodology; supervision; writing – original draft; writing – review & editing.

ORCID® iDs

Charles Garcia da Cunha - <https://orcid.org/0009-0002-8837-3989>

Isabelle M. D. Gonzaga - <https://orcid.org/0000-0001-8117-0295>

Ivo F. Teixeira - <https://orcid.org/0000-0002-4356-061X>

Elton Sitta - <https://orcid.org/0000-0003-3181-0076>

Data Availability Statement

All data that supports the findings of this study is available in the published article and/or the supporting information of this article.

References

- Amini Horri, B.; Ozcan, H. *Curr. Opin. Green Sustainable Chem.* **2024**, *47*, 100932. doi:10.1016/j.cogsc.2024.100932
- Zainal, B. S.; Ker, P. J.; Mohamed, H.; Ong, H. C.; Fattah, I. M. R.; Rahman, S. M. A.; Nghiem, L. D.; Mahlia, T. M. I. *Renewable Sustainable Energy Rev.* **2024**, *189*, 113941. doi:10.1016/j.rser.2023.113941
- Khan, D. A.; Choudhary, A. K.; Sharma, D. *Hydrogen Energy*; CRC Press: Boca Raton, 2024. doi:10.1201/9781003537816
- Maggio, G.; Vasta, S.; Nicita, A.; Trocino, S.; Giorgianni, M. *Energies (Basel, Switz.)* **2025**, *18*, 1439. doi:10.3390/en18061439
- Inocêncio, C. V. M.; Holade, Y.; Morais, C.; Kokoh, K. B.; Napporn, T. W. *Electrochem. Sci. Adv.* **2023**, *3*, e2100206. doi:10.1002/elsa.202100206
- El ouardi, M.; El Idrissi, A.; Arab, M.; Zbair, M.; Haspel, H.; Saadi, M.; Ait Ahsaine, H. *Int. J. Hydrogen Energy* **2024**, *51*, 1044–1067. doi:10.1016/j.ijhydene.2023.09.111
- Chen, T.-W.; Ramachandran, R.; Chen, S.-M.; Anushya, G.; Al-Sehemi, A. G.; Mariyappan, V.; Alargarsamy, S.; Alam, M. M.; Mahesh, T. C.; Kalimuthu, P.; Kannan, R. *Int. J. Electrochem. Sci.* **2024**, *19*, 100542. doi:10.1016/j.ijoes.2024.100542
- Corradini, P. G.; de Brito, J. F.; Blaskievicz, S. F.; Salvati, B. S.; Menezes, B. C. e. S.; Zaroni, M. V. B.; Mascaro, L. H. *J. Photochem. Photobiol., A* **2023**, *444*, 114901. doi:10.1016/j.jphotochem.2023.114901
- Lu, G.; Lun, Z.; Liang, H.; Wang, H.; Li, Z.; Ma, W. *J. Alloys Compd.* **2019**, *772*, 122–131. doi:10.1016/j.jallcom.2018.09.064
- Orimolade, B. O.; Arotiba, O. A. *J. Electroanal. Chem.* **2020**, *878*, 114724. doi:10.1016/j.jelechem.2020.114724
- Xie, Z.; Chen, D.; Zhai, J.; Huang, Y.; Ji, H. *Appl. Catal., B* **2023**, *334*, 122865. doi:10.1016/j.apcatb.2023.122865
- Gonzaga, I. M. D.; Gonçalves, R.; Fernandes, C. H. M.; Assis, M.; Teixeira, I. F.; Mascaro, L. H. *Chemosphere* **2024**, *352*, 141315. doi:10.1016/j.chemosphere.2024.141315
- Schlomberg, H.; Kröger, J.; Savasci, G.; Terban, M. W.; Bette, S.; Moudrakovski, I.; Duppel, V.; Podjaski, F.; Siegel, R.; Senker, J.; Dinnebier, R. E.; Ochsenfeld, C.; Lotsch, B. V. *Chem. Mater.* **2019**, *31*, 7478–7486. doi:10.1021/acs.chemmater.9b02199
- Bojdys, M. J.; Müller, J.-O.; Antonietti, M.; Thomas, A. *Chem. – Eur. J.* **2008**, *14*, 8177–8182. doi:10.1002/chem.200800190
- Chen, Z.; Savateev, A.; Pronkin, S.; Papaefthimiou, V.; Wolff, C.; Willinger, M. G.; Willinger, E.; Neher, D.; Antonietti, M.; Dontsova, D. *Adv. Mater. (Weinheim, Ger.)* **2017**, *29*, 1700555. doi:10.1002/adma.201700555
- Dontsova, D.; Pronkin, S.; Wehle, M.; Chen, Z.; Fettkenhauer, C.; Clavel, G.; Antonietti, M. *Chem. Mater.* **2015**, *27*, 5170–5179. doi:10.1021/acs.chemmater.5b00812
- Cao, S.; Low, J.; Yu, J.; Jaroniec, M. *Adv. Mater. (Weinheim, Ger.)* **2015**, *27*, 2150–2176. doi:10.1002/adma.201500033
- Ansari, S. A.; Ansari, M. O.; Cho, M. H. *Sci. Rep.* **2016**, *6*, 27713. doi:10.1038/srep27713
- da Silva, M. A. R.; Rocha, G. F. S. R.; Diab, G. A. A.; Cunha, C. S.; Pastana, V. G. S.; Teixeira, I. F. *Chem. Eng. J.* **2023**, *460*, 141068. doi:10.1016/j.cej.2022.141068
- Huang, Y.-C.; Chen, J.; Lu, Y.-R.; Arul, K. T.; Ohigashi, T.; Chen, J.-L.; Chen, C.-L.; Shen, S.; Chou, W.-C.; Pong, W.-F.; Dong, C.-L. *J. Electron Spectrosc. Relat. Phenom.* **2023**, *264*, 147319. doi:10.1016/j.elspec.2023.147319
- Blaskievicz, S. F.; Teixeira, I. F.; Mascaro, L. H. *J. Solid State Electrochem.* **2025**, *29*, 1025–1034. doi:10.1007/s10008-024-06029-8
- Yang, S.; Yang, J.; Duan, M.; Kang, S.; He, S.; Chen, C. *Trans. Tianjin Univ.* **2024**, *30*, 167–177. doi:10.1007/s12209-024-00387-0
- Sun, Y.; Miao, J.; Fan, X.; Zhang, K.; Zhang, T. *Small Struct.* **2024**, *5*, 2300576. doi:10.1002/sstr.202300576
- Miao, Y.; Li, Z.; Shao, M. *ChemCatChem* **2024**, *16*, e202301321. doi:10.1002/cctc.202301321
- Hessel, C.; Moreti, L.; Yukuhiro, V. Y.; Fernández, P. S.; Sitta, E. *Electrochim. Acta* **2025**, *509*, 145300. doi:10.1016/j.electacta.2024.145300
- Liu, D.; Liu, J.-C.; Cai, W.; Ma, J.; Yang, H. B.; Xiao, H.; Li, J.; Xiong, Y.; Huang, Y.; Liu, B. *Nat. Commun.* **2019**, *10*, 1779. doi:10.1038/s41467-019-09788-5
- Hessel, C.; Perini, N.; Sitta, E. *J. Solid State Electrochem.* **2023**, *27*, 705–714. doi:10.1007/s10008-022-05363-z
- Kong, H.; Gupta, S.; Pérez-Torres, A. F.; Höhn, C.; Bogdanoff, P.; Mayer, M. T.; van de Krol, R.; Favaro, M.; Abdi, F. F. *Chem. Sci.* **2024**, *15*, 10425–10435. doi:10.1039/d4sc01651c
- Vo, T.-G.; Kao, C.-C.; Kuo, J.-L.; Chiu, C.-c.; Chiang, C.-Y. *Appl. Catal., B* **2020**, *278*, 119303. doi:10.1016/j.apcatb.2020.119303
- Lu, Y.; Lee, B. G.; Lin, C.; Liu, T.-K.; Wang, Z.; Miao, J.; Oh, S. H.; Kim, K. C.; Zhang, K.; Park, J. H. *Nat. Commun.* **2024**, *15*, 5475. doi:10.1038/s41467-024-49662-7
- Silva, I. F.; Teixeira, I. F.; Rios, R. D. F.; do Nascimento, G. M.; Binatti, I.; Victória, H. F. V.; Krambrock, K.; Cury, L. A.; Teixeira, A. P. C.; Stumpf, H. O. *J. Hazard. Mater.* **2021**, *401*, 123713. doi:10.1016/j.jhazmat.2020.123713
- Savateev, A.; Pronkin, S.; Willinger, M. G.; Antonietti, M.; Dontsova, D. *Chem. – Asian J.* **2017**, *12*, 1517–1522. doi:10.1002/asia.201700209
- Shaddad, M. N.; Hezam, M.; Arunachalam, P.; Al-Saeedan, N. M.; Gimenez, S.; Bisquert, J.; Al-Mayouf, A. M. *Mater. Lett.* **2022**, *325*, 132799. doi:10.1016/j.matlet.2022.132799
- Chen, Z.; Dinh, H. N.; Miller, E. *Photoelectrochemical Water Splitting*; Springer Briefs in Energy; Springer New York: New York, NY, 2013. doi:10.1007/978-1-4614-8298-7
- Cheng, B.; Wang, W.; Shi, L.; Zhang, J.; Ran, J.; Yu, H. *Int. J. Photoenergy* **2012**, *2012*, 797968. doi:10.1155/2012/797968
- Coelho, D.; Gaudêncio, J. P. R. S.; Carminati, S. A.; Ribeiro, F. W. P.; Nogueira, A. F.; Mascaro, L. H. *Chem. Eng. J.* **2020**, *399*, 125836. doi:10.1016/j.cej.2020.125836
- Starukh, H.; Praus, P. *Catalysts* **2020**, *10*, 1119. doi:10.3390/catal10101119
- Pingmuang, K.; Chen, J.; Kangwansupamonkon, W.; Wallace, G. G.; Phanichphant, S.; Nattestad, A. *Sci. Rep.* **2017**, *7*, 8929. doi:10.1038/s41598-017-09514-5
- Savateev, A.; Dontsova, D.; Kurpil, B.; Antonietti, M. *J. Catal.* **2017**, *350*, 203–211. doi:10.1016/j.jcat.2017.02.029

License and Terms

This is an open access article licensed under the terms of the Beilstein-Institut Open Access License Agreement (<https://www.beilstein-journals.org/bjnano/terms>), which is identical to the Creative Commons Attribution 4.0 International License

(<https://creativecommons.org/licenses/by/4.0>). The reuse of material under this license requires that the author(s), source and license are credited. Third-party material in this article could be subject to other licenses (typically indicated in the credit line), and in this case, users are required to obtain permission from the license holder to reuse the material.

The definitive version of this article is the electronic one which can be found at:

<https://doi.org/10.3762/bjnano.17.57>